

Special Issue

Solar Detoxification of Wastewater

Message from the Guest Editors

This Special Issue on "Solar Detoxification of Wastewater and Its Subsequent Applications" seeks high-quality works and topics focusing on the latest novel wastewater treatment processes using solar radiation, including, but not limited to, photocatalytic treatment, photo-Fenton, biological, water disinfection, oxidation, filtration, purification, etc., as well as practical applications of these technologies.

Guest Editors

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Deadline for manuscript submissions

closed (30 April 2019)



Processes

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